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PTO/SB/08A (05-03)

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(use as many sheets as necessary)			ssary)	Examiner Name	JOBO G. MUNSON	
Sheet	1	of	1	Attorney Docket Number	2003 P 54557 US	

	U.S. PATENT DOCUMENTS						
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		OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS	
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SISK	/1	INUMIYA, S., et al., "Fabrication of HfSION Gate Dielectrics by Plasma Oxidation and Nitridation, Optimized for 65nm node Low Power CMOS Applications," 2003 Symposium on VLSI Technology Digest of Technical Papers, pp. 18–19, Document No. 4-89114-035-6/03.	
SING.	2	WOLF, S., "Silicon Processing for the VLSI Era: Diffusion in Silicon" pp. 336-339.	

Examiner Signature	G. MUNSON	Date Considered	25 FEBRUARY 2005
DIGITATOR		Considered	

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Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it displays a valid OMB control number. Substitute for form 1449A/PTO Complete if Known **Application Number** 10/771,075 INFORMATION DISCLOSURE February 3, 2004 Filing Date l i STATEMENT BY APPLICANT First Named Inventor TBD 2811 Art Unit (use as many sheets as necessary) G. MUNSON TOD Examiner Name Attorney Docket Number 2003 P 54557 US

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STAT	1	"Front End Processes," International Technology Roadmap for Semiconductor (ITRS), 2003 Edition, pp. 23–25, http://member.itrs.net/.	

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Examiner	<u></u>	MUNSON	Date	25 FEBRUARY	2005
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